OBSERVATION OF NICKEL HYDROXIDE LAYER ON Ni ELECTRODE
BY IN SITU ATOMIC FORCE MICROSCOPY

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The layer of nickel hydroxide was formed on the surface of polycrystalline Ni immersed in 1 M KOH by cycling the potential in the range between −0.1 and 0.6 V vs. Pt in 1 M KOH. The layer thickness of 8.5 nm, estimated by an electrochemical method, corresponded to about 10 monolayers of Ni(OH)₂. The changes of thickness of the nickel hydroxide film during the process of its oxidation and reduction were monitored by the use of in situ atomic force microscopy with the tip fixed and the electrode potential scanned between −0.1 and +0.6 V at a scan rate of 100 mV/s. The process of oxidation resulted in the film thickness decrease by about 3 nm. This change could be explained as to be due to the removal of a proton from Ni(OH)₂ layer.

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1. Introduction

The immersion of metallic nickel in aqueous alkaline solution leads to the formation of the layer of nickel(II) hydroxide. The knowledge of the properties of such layers is important for applications of nickel electrodes in alkaline batteries, in the process of hydrogen evolution, electrochemical syntheses and their use as electrochromic devices.

The most essential problem which appears here is the course of the oxidation/reduction (the charging/discharging) reaction. The mechanism of this reaction is often described as [1, 2]:

$$\text{Ni(OH)}_2 \rightleftharpoons \text{NiOOH} + \text{H}^+ + e^- \quad (1)$$

or

$$\text{Ni(OH)}_2 + \text{OH}^- \rightleftharpoons \text{NiOOH} + \text{H}_2\text{O} + e^- \quad (2)$$

The first reaction assumes the diffusion of a proton from the hydroxide layer to the solution and its reaction with OH⁻ ions in the solution. The second one assumes the diffusion of OH⁻ ions from the solution to the hydroxide layer followed by the
reaction of OH\textsuperscript{-} with a proton within the Ni(OH)\textsubscript{2} layer and the formation of water molecule. It can be expected that the process (1) leads to the decrease in the layer thickness during the process of Ni(OH)\textsubscript{2} oxidation while the process (2) should be connected with the increase in the layer thickness. Häring and Kötz [3] reported the use of in situ atomic force microscopy (AFM) for measuring the swelling behavior during the oxidation and reduction of nickel hydroxide films electrochemically deposited onto highly oriented pyrolytic graphite. In our paper the nickel hydroxide layer was formed on the surface of polycrystalline nickel immersed in 1 M KOH by cycling the potential in the range between -0.1 and 0.6 V vs. Pt in 1 M KOH.

2. Experimental

Nickel plates 12 mm × 12 mm and 2 mm thick (99.99% pure) were obtained from Alfa-Johnson Matthey. These were polished with SiC emery paper and with alumina powder down to 0.05 μm.

Analar grade KOH and ultra pure water were used. The electrode was immersed in 1 M KOH and subjected to repetitive cycles from -0.1 to 0.6 V vs. Pt in 1 M KOH for 1.5 h at a scan rate of 100 mV/s. A Pt wire was used as the counter electrode. The area of the working electrode was of 0.71 cm\textsuperscript{2}.

The observations of nickel hydroxide layer on a Ni electrode were carried out with the use of Nanoscope E microscope (Digital Instruments, USA) with ECAFM software and NanoProbes Silicon Nitride cantilevers (0.12 N/m).

3. Results

The topographic image of the electrode surface, after cycling for 1.5 hours taken at the open circuit potential, is shown in Fig. 1. The observed structure is granular; the lateral size of grains and their height are of about 300 nm and 20 nm, respectively.

The changes of the Ni(OH)\textsubscript{2} film thickness were then monitored during the next step of cycling represented by Figs. 2 and 3. In this experiment the tip remained fixed at the image center and the changes in the height of the film (z direction) were recorded versus time. The resulting image (constant force mode) is shown in Fig. 4 in which the vertical axis represents the time of potential cycling experiment. Comparing the grey scale at this image one can conclude that the layer thickness changes periodically during the experiment. The dark stripes reflect the decrease in the layer thickness which occurs as the result of the film oxidation. The height profile corresponding to this image is shown in Fig. 5.

4. Discussion and conclusions

Basing on the data given by Häring and Kötz [3] one can evaluate the charge $Q_v = 1060 \, \text{C/cm}^3$ connected with the oxidation of Ni(OH)\textsubscript{2} layer of size 1 cm × 1 cm. By measuring the charge density $Q_s = 9 \times 10^{-4} \, \text{C/cm}^2$ connected with the reaction (1) (Fig. 2) and comparing this value with $Q_v$ we estimated the average thickness of Ni(OH)\textsubscript{2} layer as equal to 8.5 nm. Taking into account the X-ray diffraction data [2] we can conclude that such a layer thickness is of the
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Fig. 1. Topographic AFM image of the Ni/Ni(OH)₂ electrode surface in 1 M KOH at the open circuit potential after cycling for 1.5 h in the potential range between -0.1 to 0.6 V (constant force mode, image without corrections or filtering, image scan frequency 2.04 Hz).

Fig. 2. Cyclic voltammograms of the Ni/Ni(OH)₂ electrode in 1 M KOH (7 cycles after initial cycling for 1.5 h); sweep rate 100 mV/s.

Fig. 3. Current–time and potential–time dependences for the Ni/Ni(OH)₂ electrode in 1 M KOH during 7 cycles after initial cycling for 1.5 h.
order of 10 monolayers. As it can be seen from Figs. 4 and 5, after oxidation the film thickness decreases by about 3 nm. This change is reversed during the process of electrochemical reduction and can be repeated. The reversible thickness change connected with the charging and discharging reactions is of order of 35% relative to the thickness of the electrochemically prepared Ni(OH)$_2$ film. We can conclude that during the oxidation of Ni(OH)$_2$ film protons diffused from the hydroxide layer to the solution.

References